

**Amendments to the Specification:**

Page 7, please replace the paragraph starting in line 17 with the following amended paragraph:

The drawing is a diagrammatic illustration of a vacuum chamber in which the coating method of the present application ~~[[as]]~~ is carried out.

Page 12, please replace the paragraph starting in line 20 on page 12 and ending in line 9 on page 13 with the following amended paragraph:

A metal cup 20 containing the composition of the present application, or a crucible holding a composition tablet, is positioned on a support 22 having a suitable heater associated therewith for heating the composition to a temperature of 100-300°C and more preferably 150-200°C. After establishing a desirable vacuum of  $1 \times 10^{-4}$  to  $1 \times 10^{-6}$  torr in the vacuum chamber, the heater is energized and the solid state film forming substance in the composition evaporates by sublimation to form a molecular beam 24 of amphiphilic molecules which settle on substrate surface 26 that faces toward the source 20 of the molecular beam. The opposite surface 28 of the substrate B is not coated with the film forming substance. The amphiphilic molecules settle on substrate surface 26 and bond thereto as by covalent bonding, hydrogen bonding and/or van der Waals forces while simultaneously self-assembling into a continuous thin film. The operation is continued for a period required to form a desired film thickness. ~~[[the]]~~ The chamber is then vented and the coated substrates are removed.